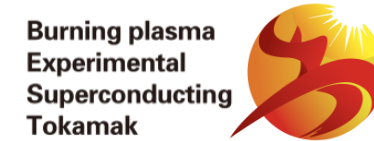




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Physics and Engineering Design of the 500 keV Beam Source for BEST Neutral Beam Injector

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- 02 Overall Design of Beam Source**
- 03 Key Design of Plasma Source**
- 04 Key Design of Accelerator**
- 05 Summary & Future Plans**

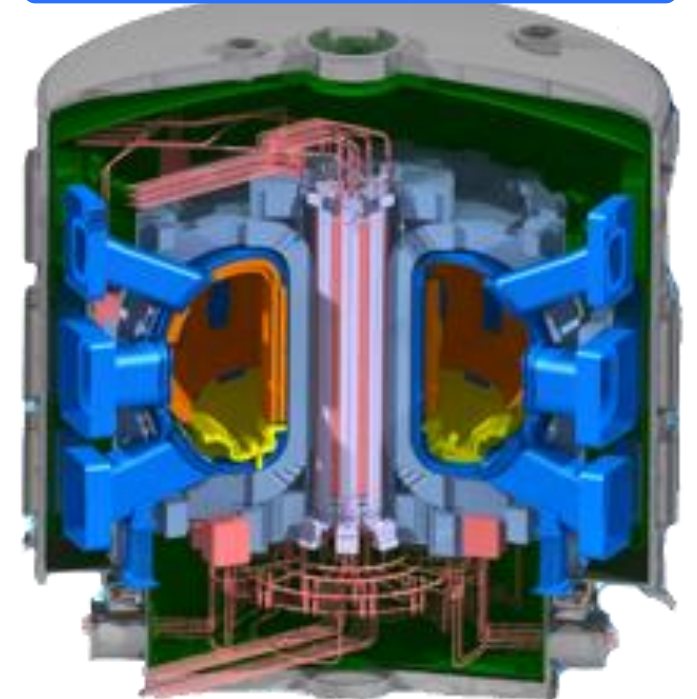
- | **Burning plasma Superconducting Tokamak** with High-Jc superconductor
- | Object: **to generate electricity from fusion power** for the first time on Earth

| Main design parameters of JT-60SA, ITER & BEST

Key Design	JT-60SA	ITER	BEST	
Species	DD	DD, DT	DD, DT	
Major Radius	3.0 m	6.2 m	3.6 m	
Minor Radius	1.18 m	2.0 m	1.1 m	
Toroidal Field	2.3 T	5.3 T	6.1 T	
Plasma Current	5.5 MA	15.0 MA	2.8 MA (S.S.)	7.0 MA (ind.)
Fusion Power	--	500 MW	10 MW (S.S.)	160 MW (ind.)
Energy Gain Q	--	10	0.3 (S.S.)	5 (ind.)
Pulse Length	100 s (ind.)	400 s (ind.)	1~4 h (S.S.)	10 s (ind.)

S.S.=steady-state operation, ind.=inductive operation

| Higher field → Higher confinement

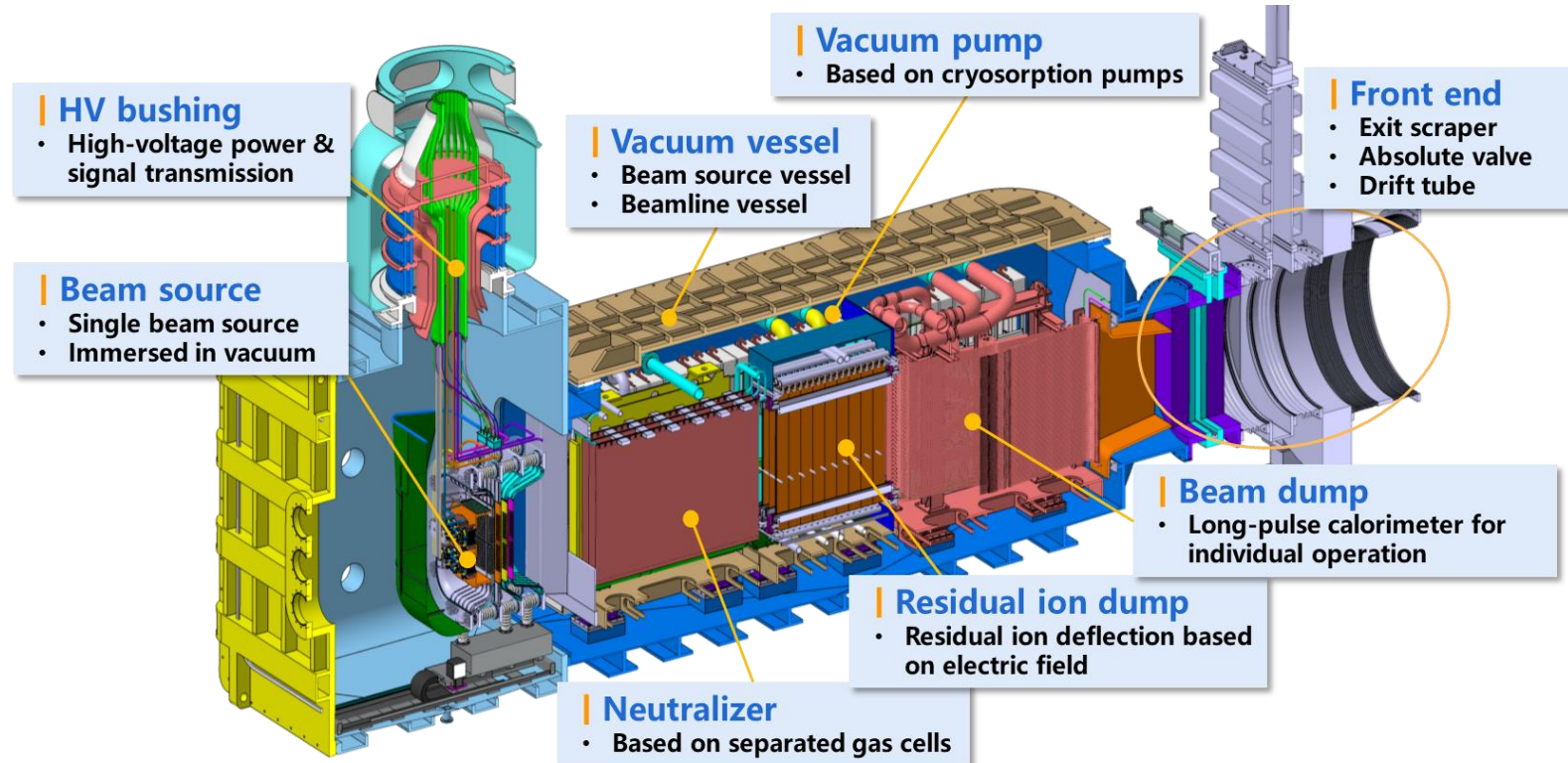


| For plasma heating & current drive, burning control, **essential for $Q > 5$ scenario**

| **Negative ion source based** neutral beam injector, ITER-like structure

Basic requirements of BEST NBI

BEST NBI	Phase I	Phase II
Species	D^0	D^0
Injection Power	4 MW	10 MW
Beam Energy	500 keV	800 keV
Pulse Duration	≥ 1000 s	≥ 1000 s
Structure	One Injector with One Beam Source	
Layout	Injection Angle 31° Tangency Radius 3.12 m	

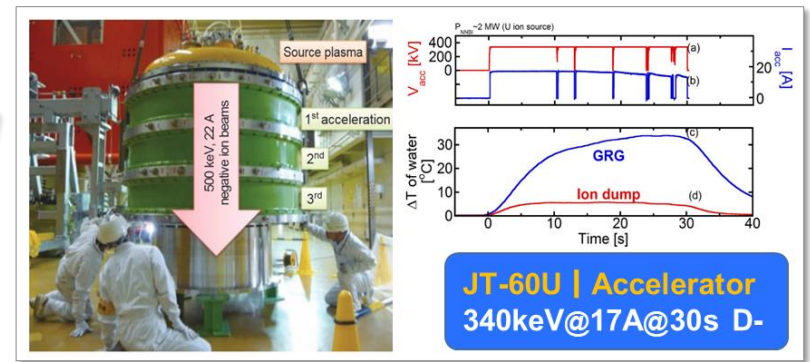
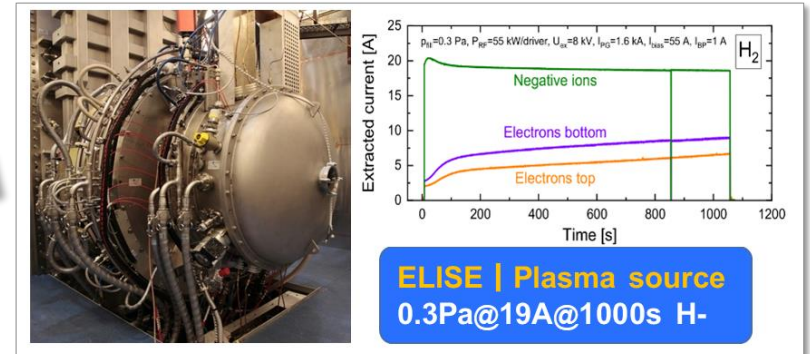
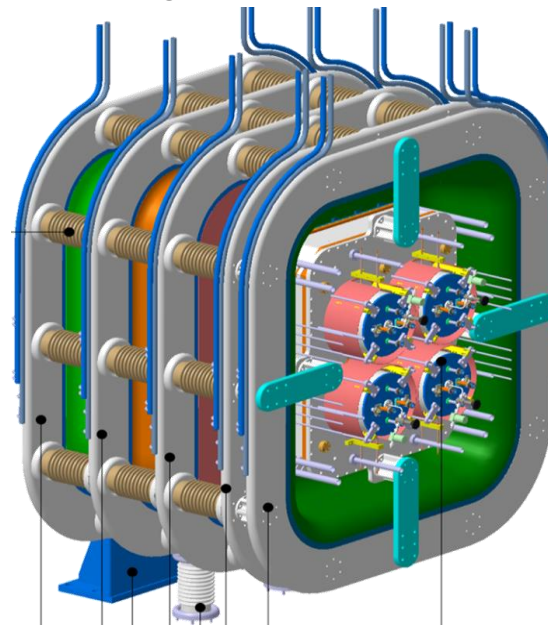


| **RF driven & Cs seeded** plasma source + **multi-aperture & multi-stage** accelerator

| Based on **R&D experience worldwide** and R&D activities of CRAFT NNBI project

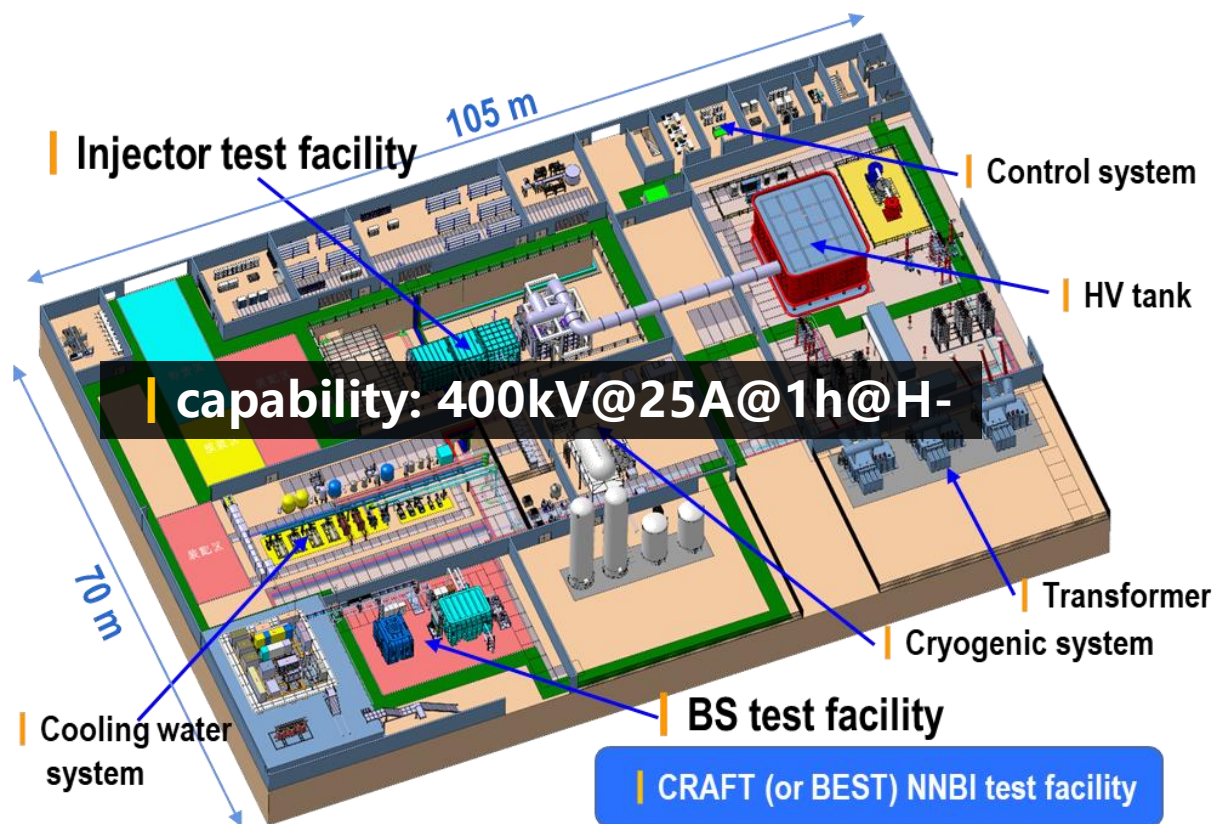
	JT-60SA	ITER	BEST-I
Species	D-	D-	D-
$\eta_{\text{transport}}$	45.6%	41.2%	40%
P_{D-} (MW)	11	40	10
E_{D-} (keV)	500	1000	500
t (s)	100	3600	1000
η_{strip}	--	≤ 0.3	≤ 0.25
J_e/J_{D-}	≤ 1	≤ 1	≤ 1
θ_{div} (mrad)	≤ 7	≤ 7	≤ 7

Design of BS-500keV

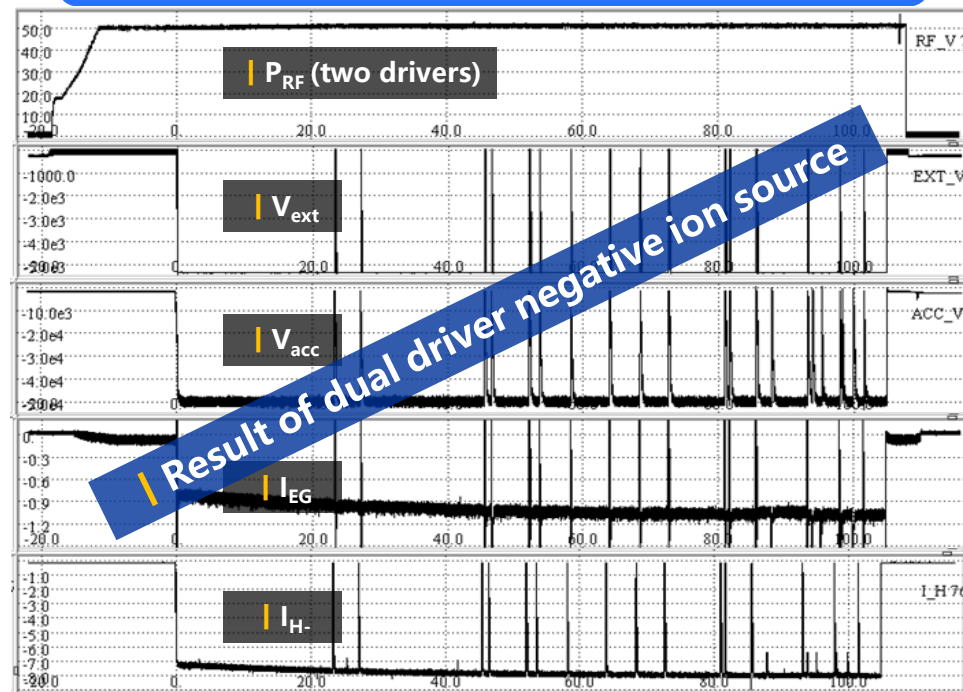


| **RF driven & Cs seeded** plasma source + **multi-aperture & multi-stage** accelerator

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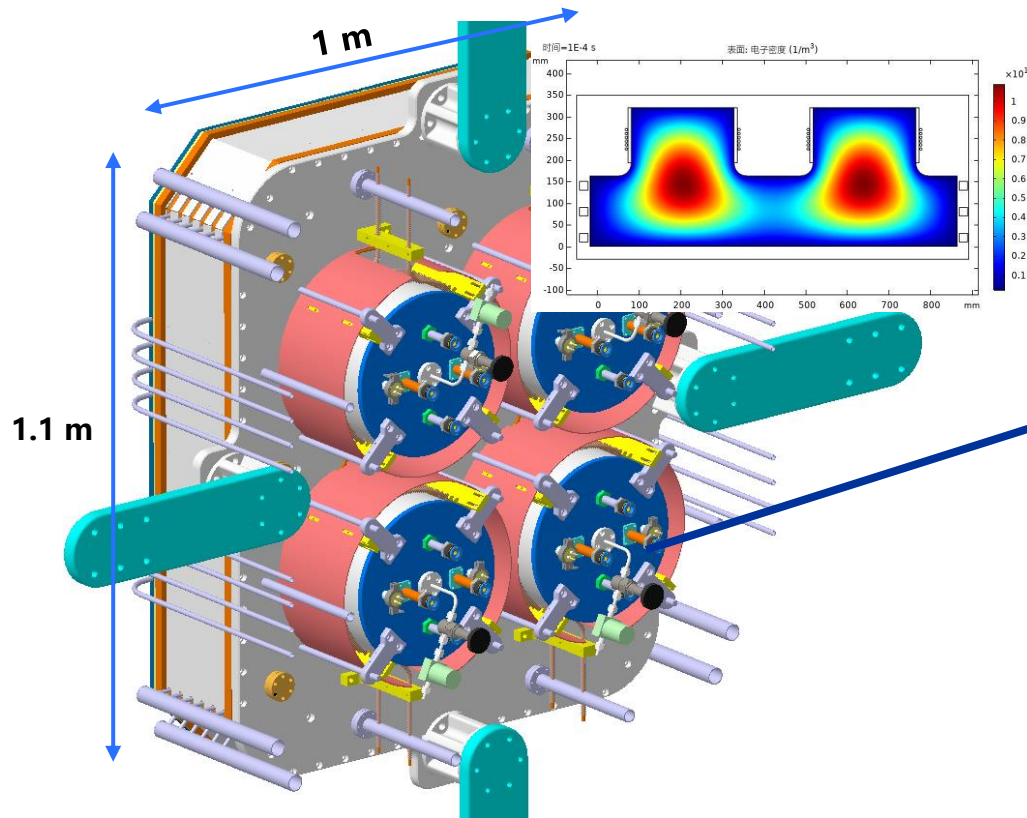


| 7.7A (130A/m²) @ 0.4Pa @ 55kV @ 105s
 | 13.0A (220A/m²) @ 0.4Pa @ 51kV @ 10s



| RF driver: **1MHz@45kW/driver** → 200A/m² H-; 2MHz & longer tube will be tested

| Expansion chamber: **Larger cross section** of 1.1×1 m² (vs ELISE) for better beam uniformity



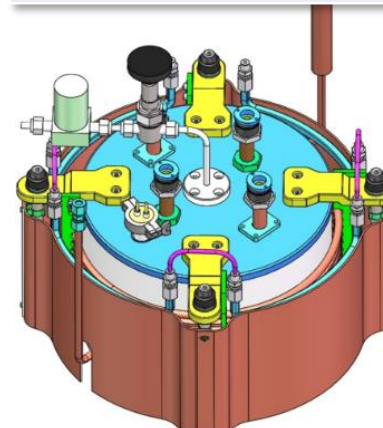
Design Parameters

1 MHz

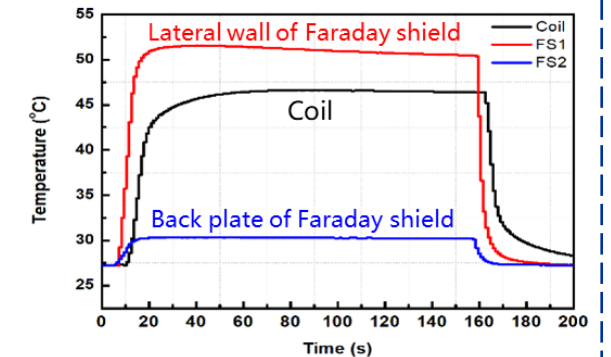
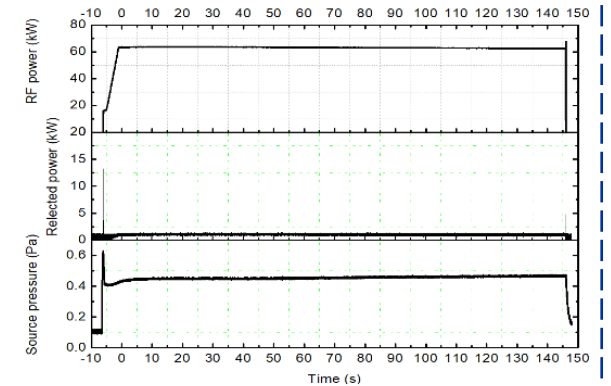
80kW/driver

6.5 turns

φ270mm, h130mm



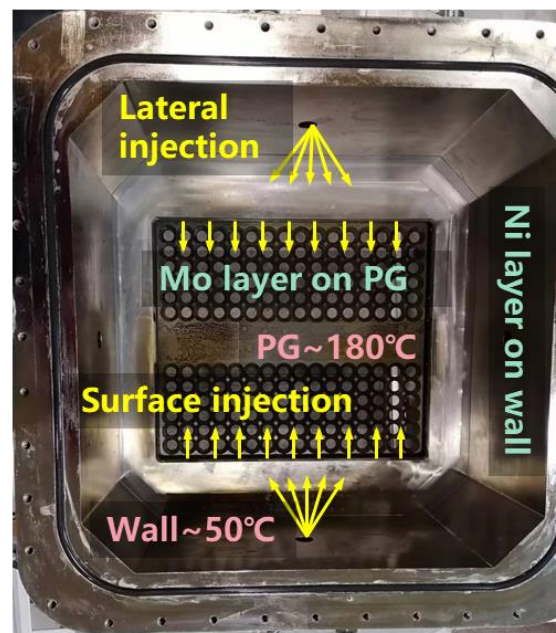
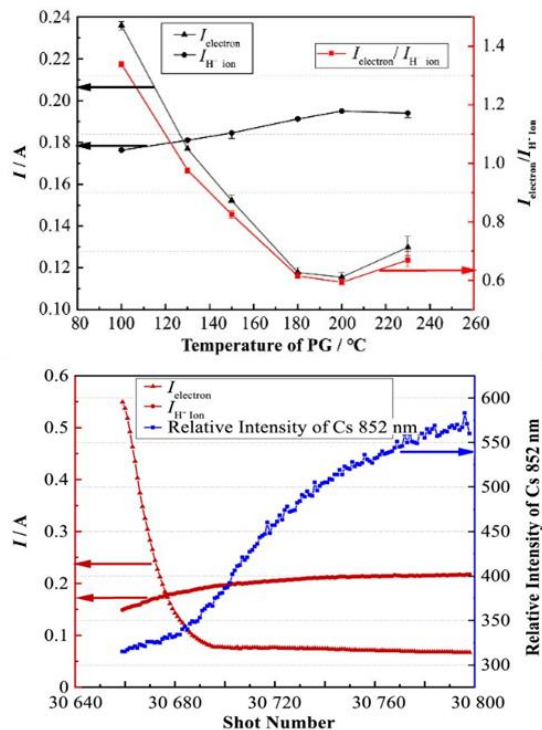
60kW@150s discharge & water Δt



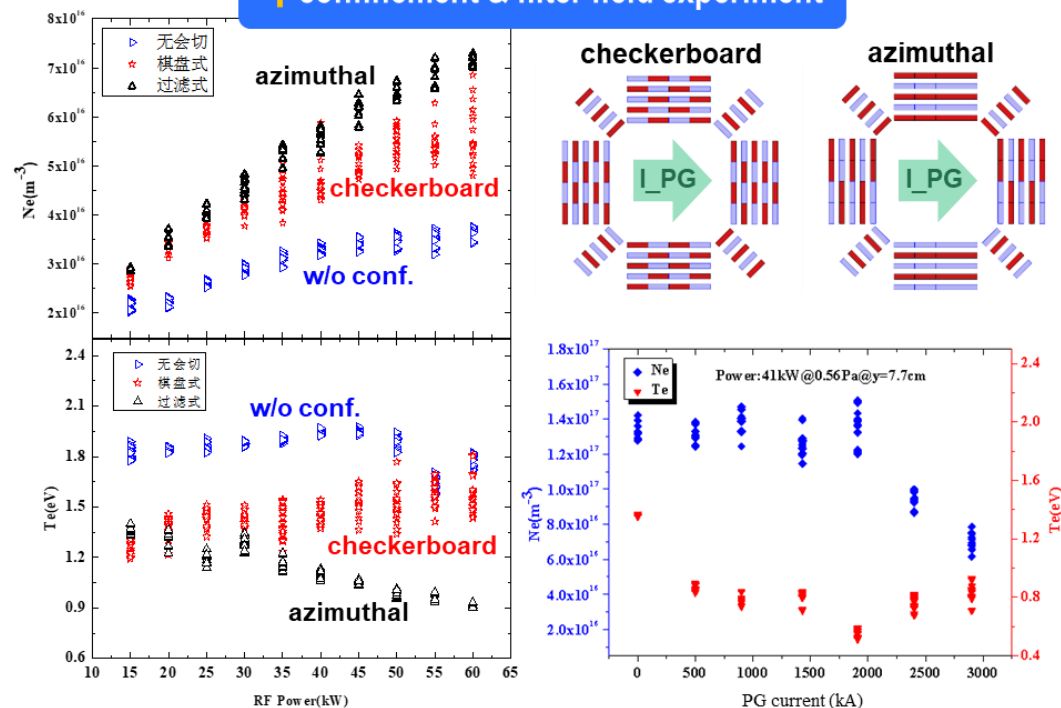
| Cs seeding: Sensitive to T_{PG} (optimal 180°C) and **surface injection** (but increase breakdown)

| Confinement/Filter field: **Lower e/H- with conf. field**; $I_{PG} \sim 1000A$ w/o $I_{return} \rightarrow 200A/m^2$ H-

Cs relative experiments



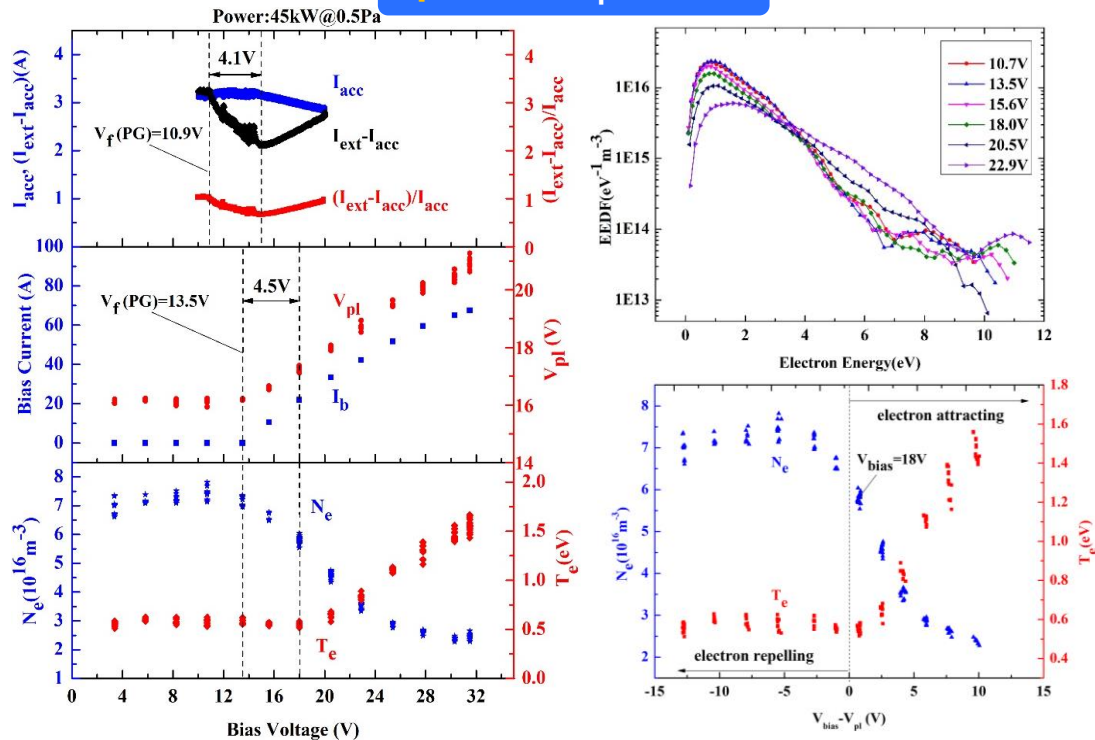
confinement & filter field experiment



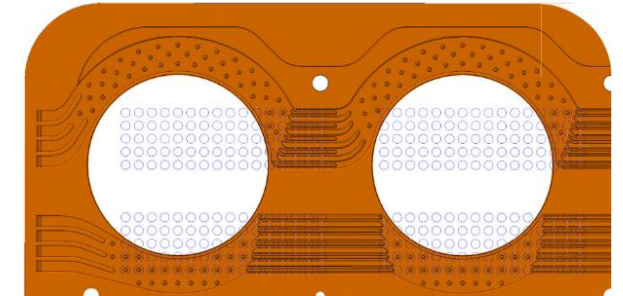
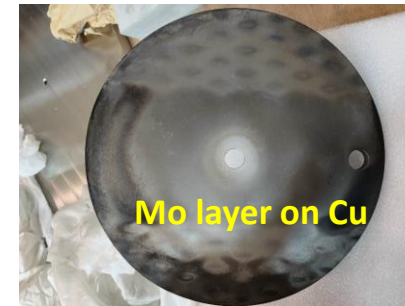
| PG Bias: $V_{bias} \sim 15V$ (BP floating) \rightarrow 200A/m² H-; Optimal V_{bias} for e/H- (repeated experiments)

| Backstream ions: Source backplate adopts **Mo-Cu composite structure** (Mo \sim 1mm)

PG bias experiments



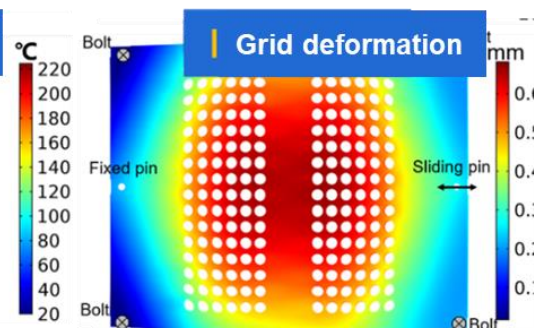
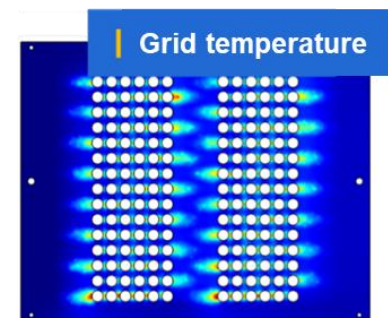
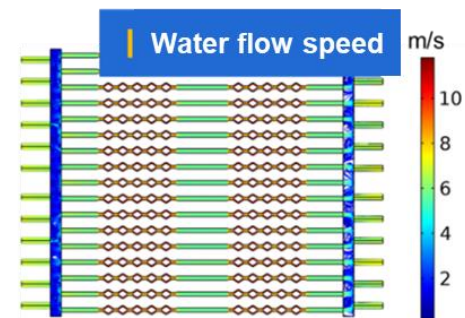
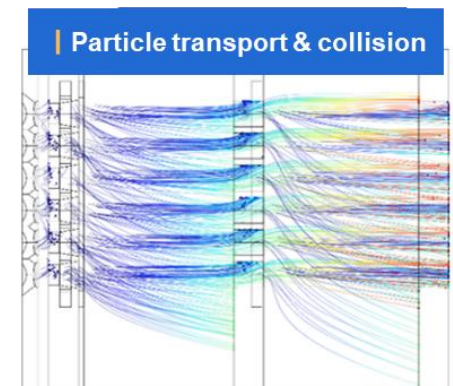
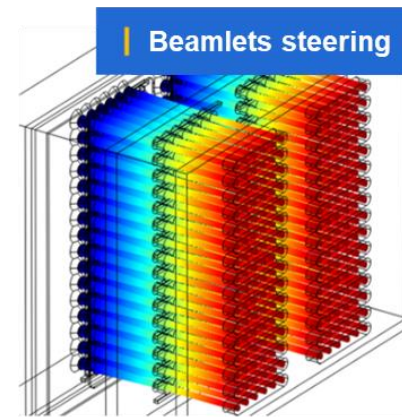
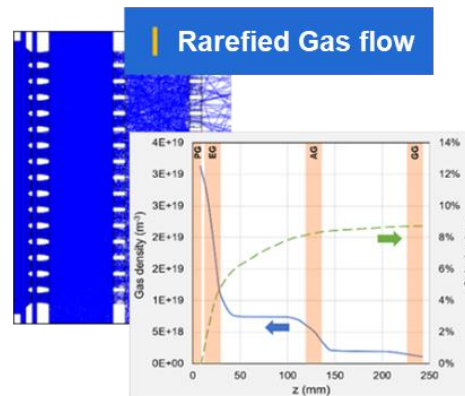
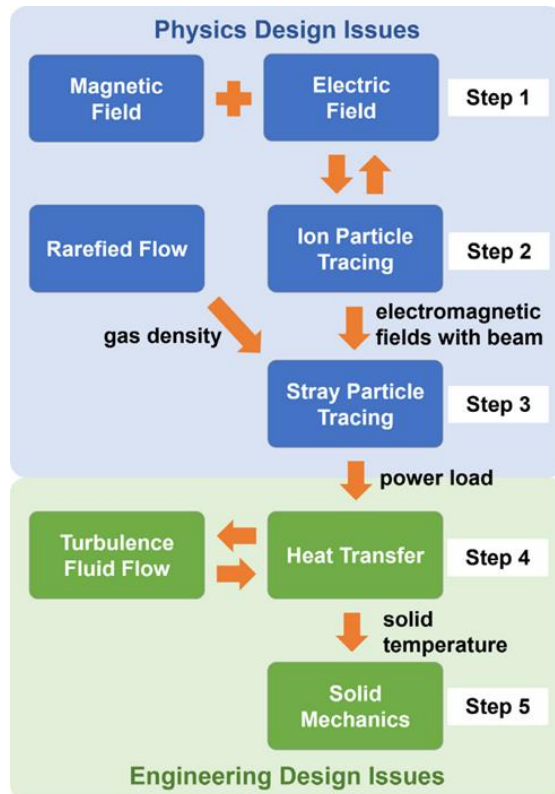
Backstream ions



	Atomic density	Sputtering yield (300keV D ₂ ⁺)	Sputtering flux (80A/m ² D ₂ ⁺)	Time for 1μm sputtering
Cu	8.4e22 m ⁻³	1e-2	1.0e15	2.3h
Mo	6.4e22 m ⁻³	2e-3	2e14	9.0h

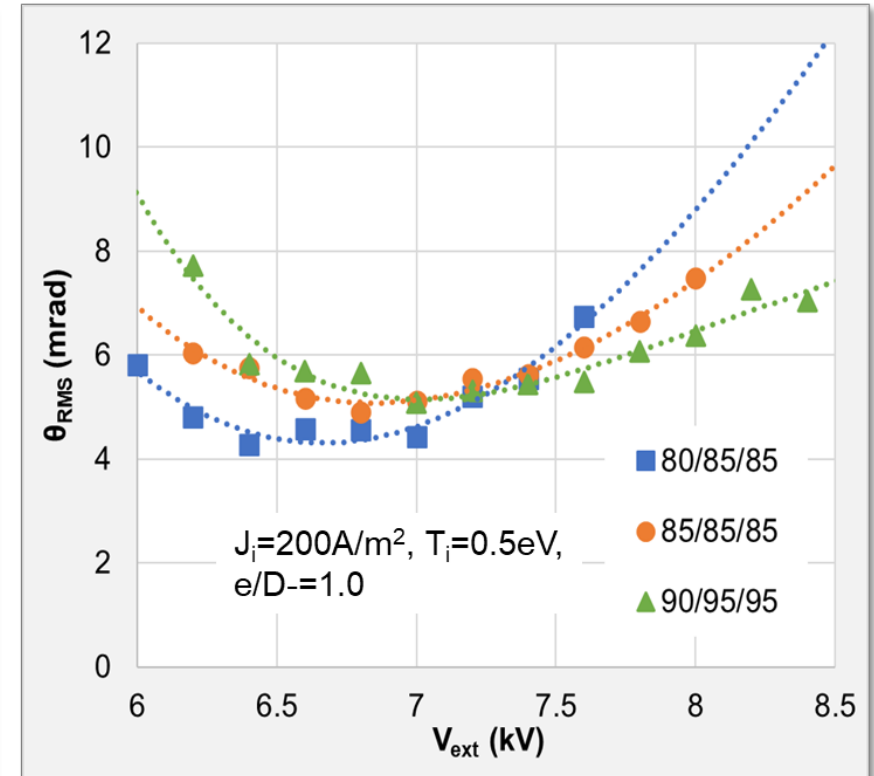
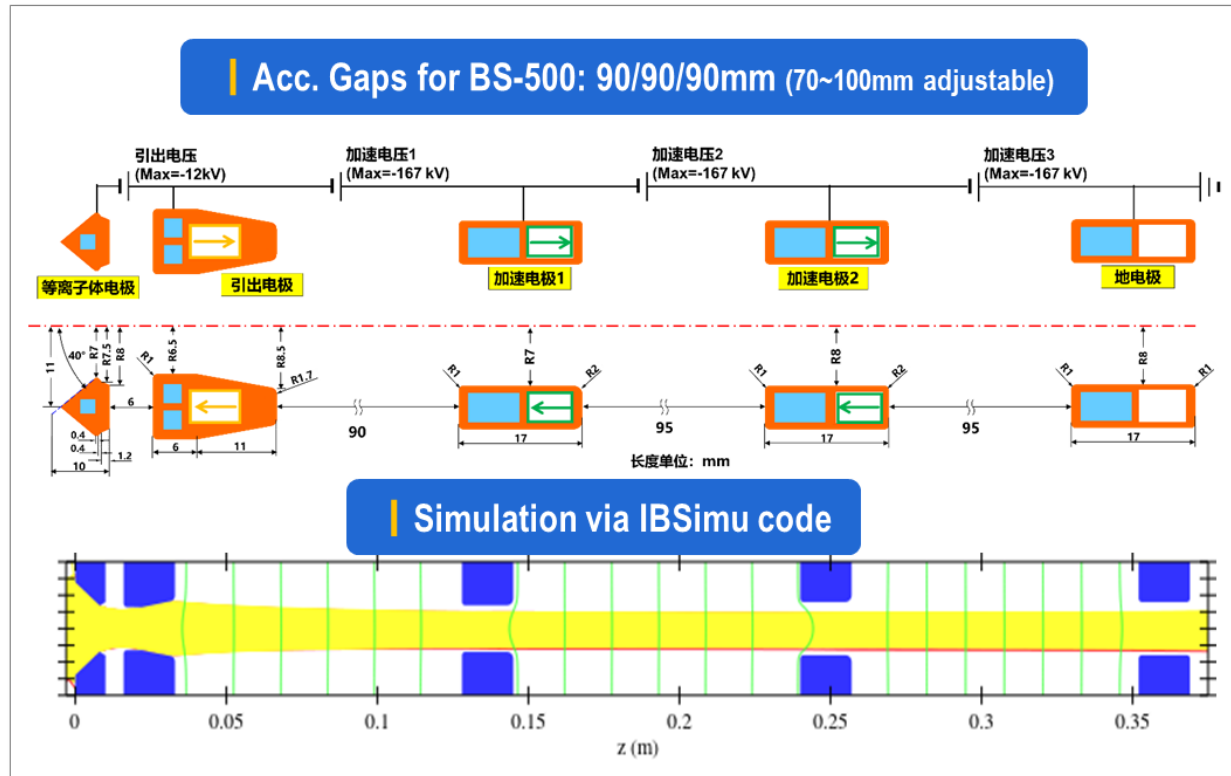
| Based on the design or experimental results of **JT-60SA/LHD/ITER**

| **Multiphysics modeling** including almost physics and engineering issues of an accelerator

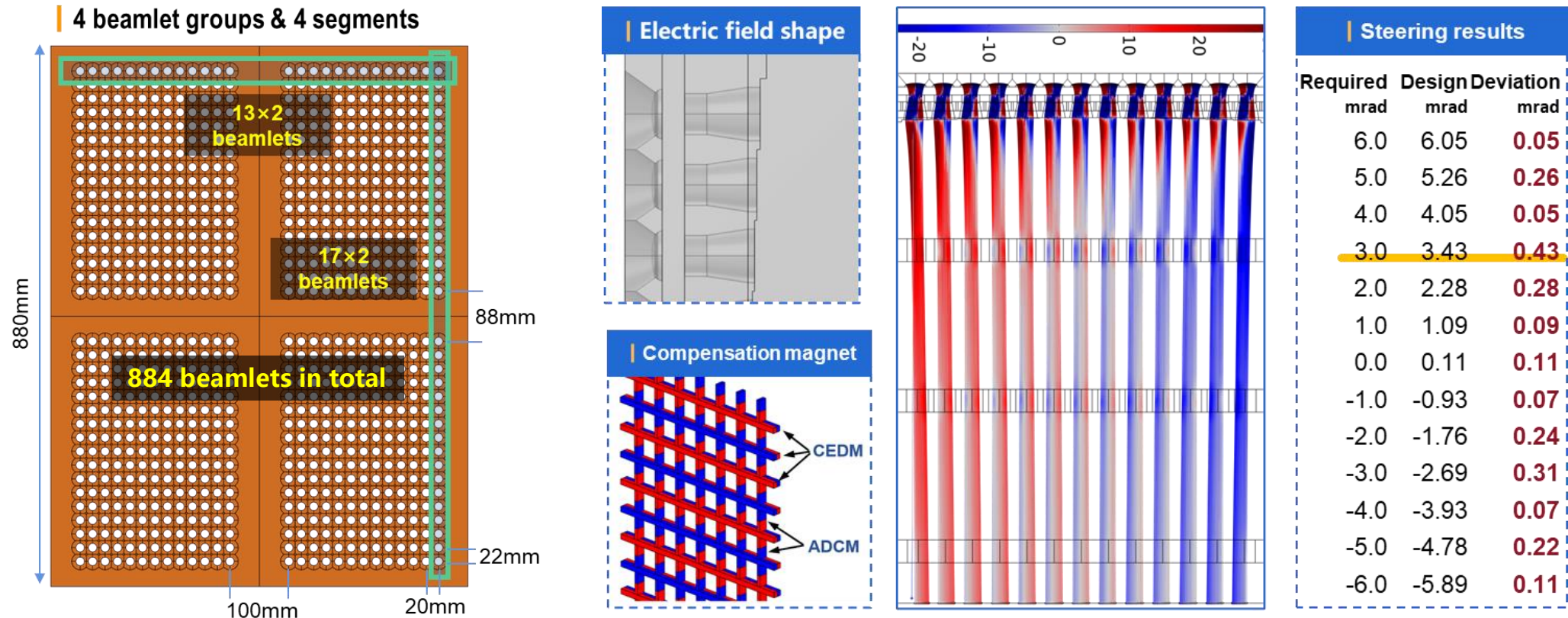


| **Electrode structure:** PG/EG/AG1/AG2/GG aperture~14/13/14/16/16mm

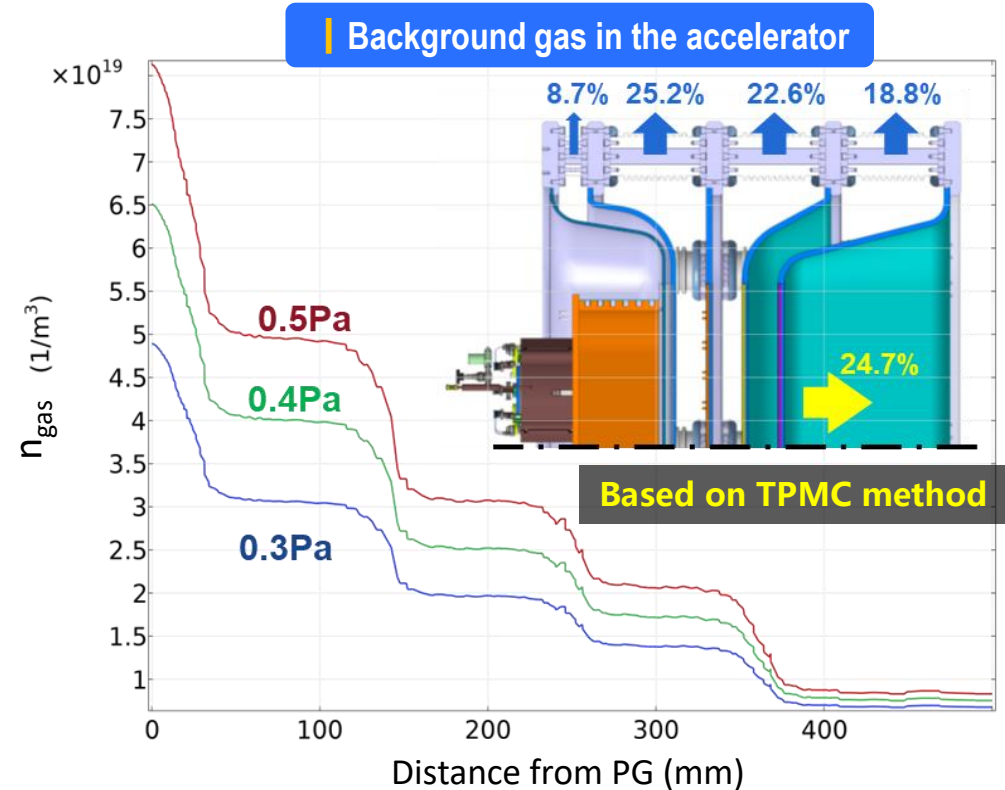
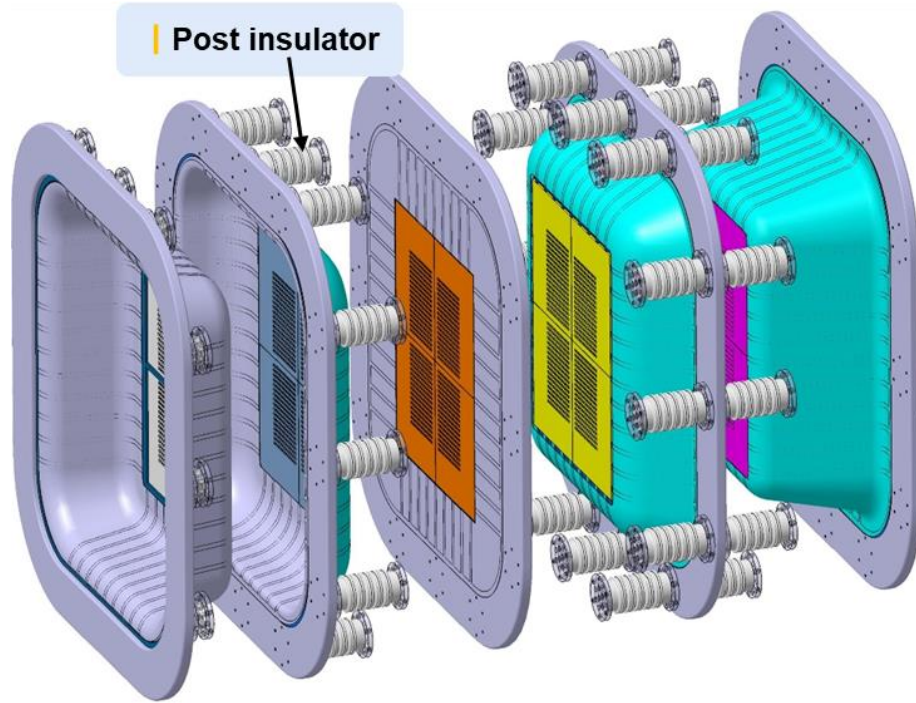
| Single beamlet optics: **Acc. gap~90/95/95mm** for 200A/m² D- (for better HV holding)



- | Multi-beamlet focusing: **Multi-step of E field shaping** to steer all beamlets to a point
- | Deflection compensation: **Crisscross magnets** to compensate magnetic deflection



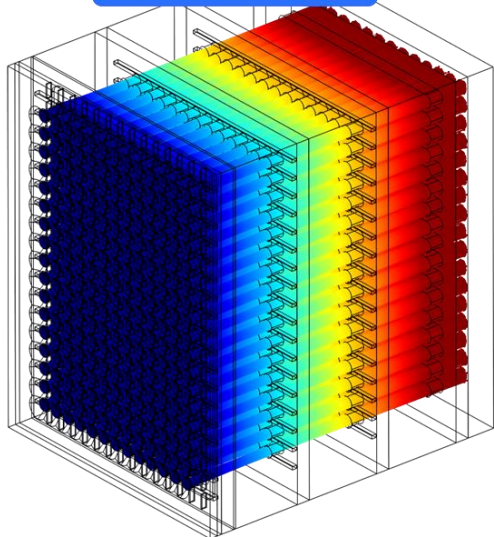
- | High voltage holding: **Source immersed in vacuum** for better insulation
- | Stripping loss (~22% at 0.3Pa): **Lateral gas pumping (~75%)** by using post insulators



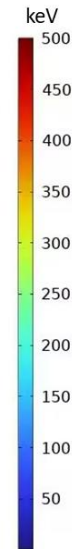
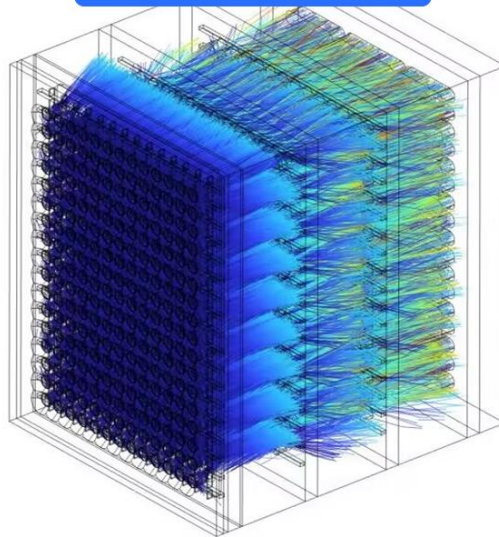
- | Stray particles: by simulation of **Particle-gas** & **Particle-electrode** during particle transport
- | Most of power deposition on electrode is from **stray electron** by **deflection magnets**

- Single stripping: $D^- + D_2 \rightarrow D^0 + D_2 + e$
- Double stripping: $D^- + D_2 \rightarrow D^+ + D_2 + 2e$
- Electron loss: $D^0 + D_2 \rightarrow D^+ + D_2 + e$
- Gas ionization: $D^-/D^0/D^+ + D_2 \rightarrow D^-/D^0/D^+ + D_2^+ + e$
- Secondary electron: $D^-/D^0/D^+/e + D_2 \rightarrow e$

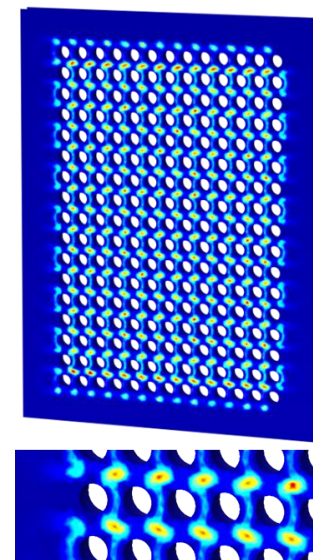
| D- trajectories



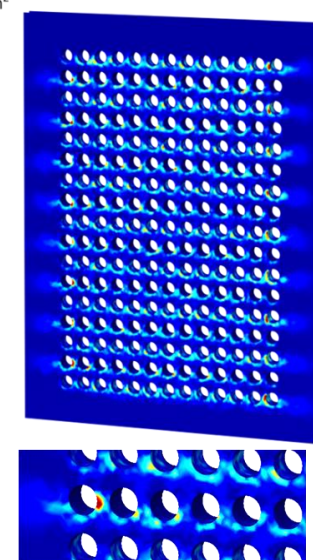
| electron trajectories



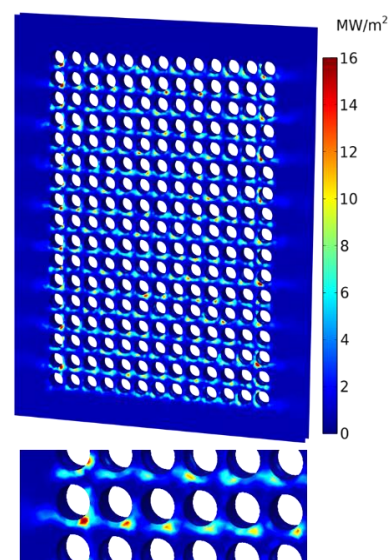
EG | 213kW



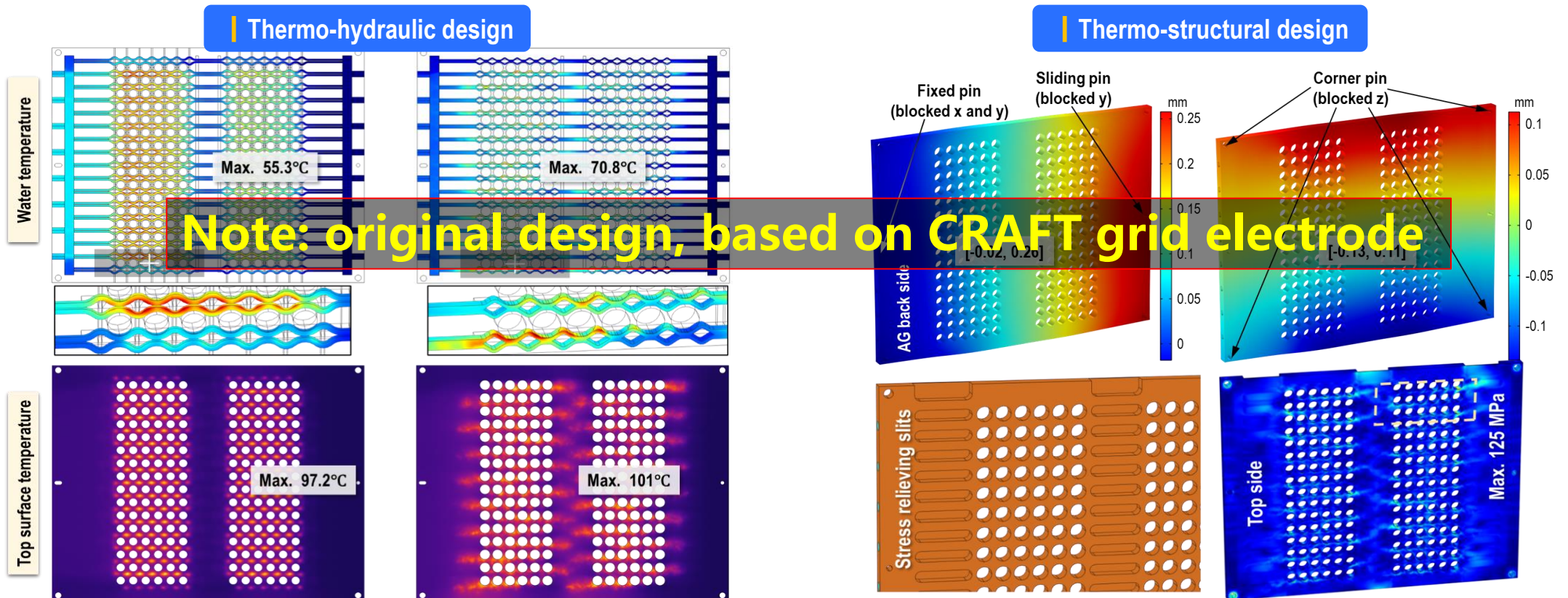
AG1 | 722kW



AG2 | 767kW

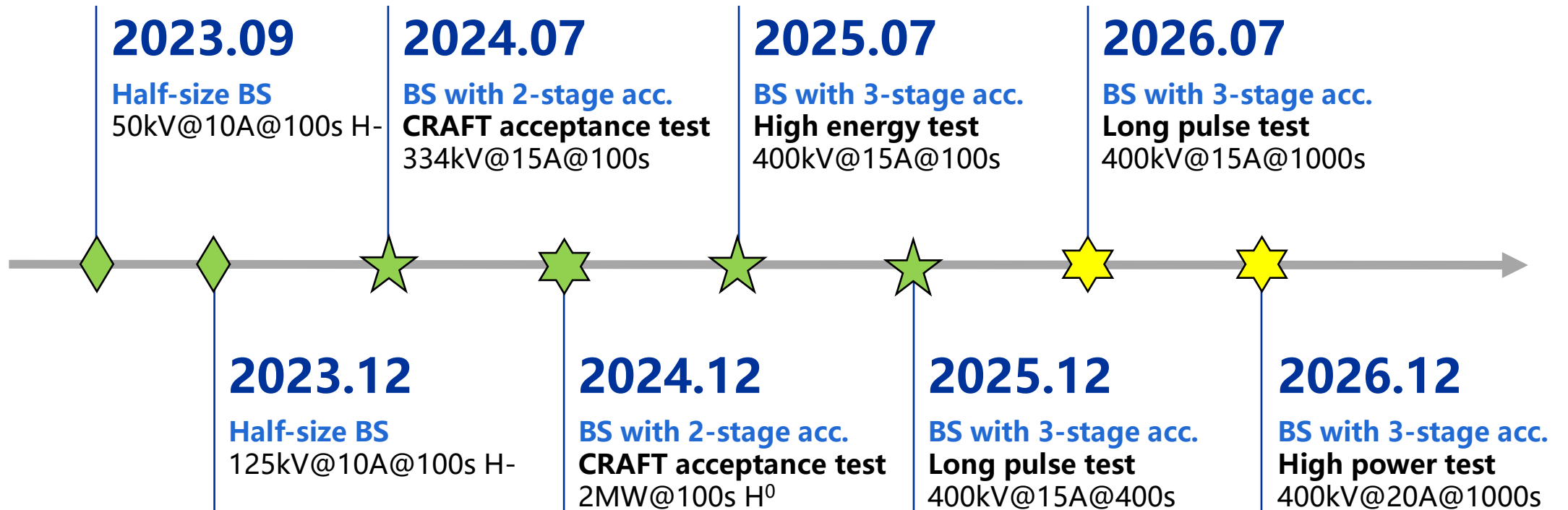


- | Cooling design for electrode : **Narrow channels** (for high water speed) **close to** hot spots
- | Assembly design for electrode : **Synergy the thermal deformation** among different electrodes



For 500keV BS	Contents
Conceptual/ Parametric	<ul style="list-style-type: none"> • Identify overall design requirements and parameters • Identify RF-driven plasma source and MAMuG accelerator
Plasma Source	<ul style="list-style-type: none"> • Take ELISE plasma source as reference • Base on results of single/dual driver negative ion source of CRAFT • Include RF driver, expanding chamber, Cs injection & recycle, magnetic field, electron suppression, backstream ion protection
Accelerator	<ul style="list-style-type: none"> • Take JT-60/ITER accelerator as reference • Base on multi-physics design model • Include single beamlet optics, multi-beamlet steering, high voltage holding, stripping loss, stray particles, thermo-mechanics

Milestones of R&D on 500keV BS



Thanks !

Q&A

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